

UNIT - 6

IMPLEMENTATION OF FFT ALGORITHMS: Introduction, An FFT Algorithm for DFT Computation, Overflow and Scaling, Bit-Reversed Index Generation & Implementation on the TMS320C54xx.

UNIT - 7

INTERFACING MEMORY AND PARALLEL I/O PERIPHERALS TO DSP DEVICES: Introduction, Memory Space Organization, External Bus Interfacing Signals. Memory Interface, Parallel I/O Interface, Programmed I/O, Interrupts and I / O Direct Memory Access (DMA).

UNIT - 8

INTERFACING AND APPLICATIONS OF DSP PROCESSOR: Introduction, Synchronous Serial Interface, A CODEC Interface Circuit. DSP Based Bio-telemetry Receiver, A Speech Processing System, An Image Processing System.

TEXT BOOK:

1. **"Digital Signal Processing"**, Avatar Singh and S. Srinivasan, Thomson Learning, 2004.

REFERENCE BOOKS:

1. **Digital Signal Processing: A practical approach**, Ifeachor E. C., Jervis B. W Pearson-Education, PHI/ 2002
2. **"Digital Signal Processors"**, B Venkataramani and M Bhaskar TMH, 2nd, 2010
3. **"Architectures for Digital Signal Processing"**, Peter Pirsch John Weily, 2008

MICRO AND SMART SYSTEMS TECHNOLOGY

Subject Code	: 10MS752	IA Marks	: 25
No. of Lecture Hrs./ Week	: 04	Exam Hours	: 03
Total No. of Lecture Hrs.	: 52	Exam Marks	: 10
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UNIT - 1

INTRODUCTION TO MICRO AND SMART SYSTEMS:

a) What are smart-material systems? Evolution of smart materials, structures and systems. Components of a smart system. Application areas. Commercial products.

b) What are microsystems? Feynman's vision. Micromachined transducers. Evolution of micro-manufacturing. Multi-disciplinary aspects. Applications areas. Commercial products.

UNIT - 2

MICRO AND SMART DEVICES AND SYSTEMS: PRINCIPLES AND MATERIALS:

- a) Definitions and salient features of sensors, actuators, and systems.
- b) Sensors: silicon capacitive accelerometer, piezo-resistive pressure sensor, blood analyzer, conductometric gas sensor, fiber-optic gyroscope and surface-acoustic-wave based wireless strain sensor.
- c) Actuators: silicon micro-mirror arrays, piezo-electric based inkjet print-head, electrostatic comb-drive and micromotor, magnetic micro relay, shape-memory-alloy based actuator, electro-thermal actuator.
- d) Systems: micro gas turbine, portable clinical analyzer, active noise control in a helicopter cabin.

UNIT - 3

MICROMANUFACTURING AND MATERIAL PROCESSING:

- a. Silicon wafer processing, lithography, thin-film deposition, etching (wet and dry), wafer-bonding, and metallization.
- b. Silicon micromachining: surface, bulk, moulding, bonding based process flows.
- c. Thick-film processing:
- d. Smart material processing:
- e. Processing of other materials: ceramics, polymers and metals
- f. Emerging trends

UNIT - 4

MODELING:

- a. Scaling issues.
- b. Elastic deformation and stress analysis of beams and plates. Residual stresses and stress gradients. Thermal loading. Heat transfer issues. Basic fluids issues.
- c. Electrostatics. Coupled electromechanics. Electromagnetic actuation. Capillary electro-phoresis. Piezoresistive modeling. Piezoelectric modeling. Magnetostrictive actuators.

UNIT - 5

COMPUTER-AIDED SIMULATION AND DESIGN:

Background to the finite element method. Coupled-domain simulations using Matlab. Commercial software.

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UNIT - 6

ELECTRONICS, CIRCUITS AND CONTROL:

Carrier concentrations, semiconductor diodes, transistors, MOSFET amplifiers, operational amplifiers. Basic Op-Amp circuits. Charge-measuring circuits. Examples from microsystems. Transfer function, state-space modeling, stability, PID controllers, and model order reduction. Examples from smart systems and micromachined accelerometer or a thermal cyclor.

UNIT - 7

INTEGRATION AND PACKAGING OF MICROELECTRO MECHANICAL SYSTEMS:

Integration of microelectronics and micro devices at wafer and chip levels. Microelectronic packaging: wire and ball bonding, flip-chip. Low-temperature-cofired-ceramic (LTCC) multi-chip-module technology. Microsystem packaging examples.

UNIT - 8

CASE STUDIES:

BEL pressure sensor, thermal cyclor for DNA amplification, and active vibration control of a beam.

UNIT - 9

Mini-projects and class-demonstrations (not for Examination)

- a) CAD lab (coupled field simulation of electrostatic-elastic actuation with fluid effect)
- b) BEL pressure sensor
- c) Thermal-cyclor for PCR
- d) Active control of a cantilever beam

TEXT BOOKS AND A CD-SUPPLEMENT:

1. **MEMS & Microsystems: Design and Manufacture**, Tai-Ran Tsu, Tata Mc-Graw-Hill.
2. **"Micro and Smart Systems"** by Dr. A.K.Aatre, Prof. Ananth Suresh, Prof.K.J.Vinoy, Prof. S. Gopalakrishna,, Prof. K.N.Bhat.,John Wiley Publications.

REFERENCE BOOKS:

1. Animations of working principles, process flows and processing techniques, A CD-supplement with Matlab codes, photographs and movie clips of processing machinery and working devices.

2. **Laboratory hardware kits for (i) BEL pressure sensor, (ii) thermal-cycler and (iii) active control of a cantilever beam.**
1. **Microsystems Design**, S. D. Senturia, 2001, Kluwer Academic Publishers, Boston, USA. ISBN 0-7923-7246-8.
2. **Analysis and Design Principles of MEMS Devices**, Minhang Bao, Elsevier, Amsterdam, The Netherlands, ISBN 0-444-51616-6.
3. **Design and Development Methodologies**, Smart Material Systems and MEMS: V. Varadan, K. J. Vinoy, S. Gopalakrishnan, Wiley.
4. **MEMS**- Nitaigour Premchand Mahalik, TMH 2007



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